

*Lasers in Manufacturing, LIM 2007, Munich ICM International Congress Centre Munich
Messegelände An der Poin, D-81823 München 18 – 22 June 2007*

*Micro-processing of Glass
with
Femtosecond Laser Pulses*

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¹Osaka University,

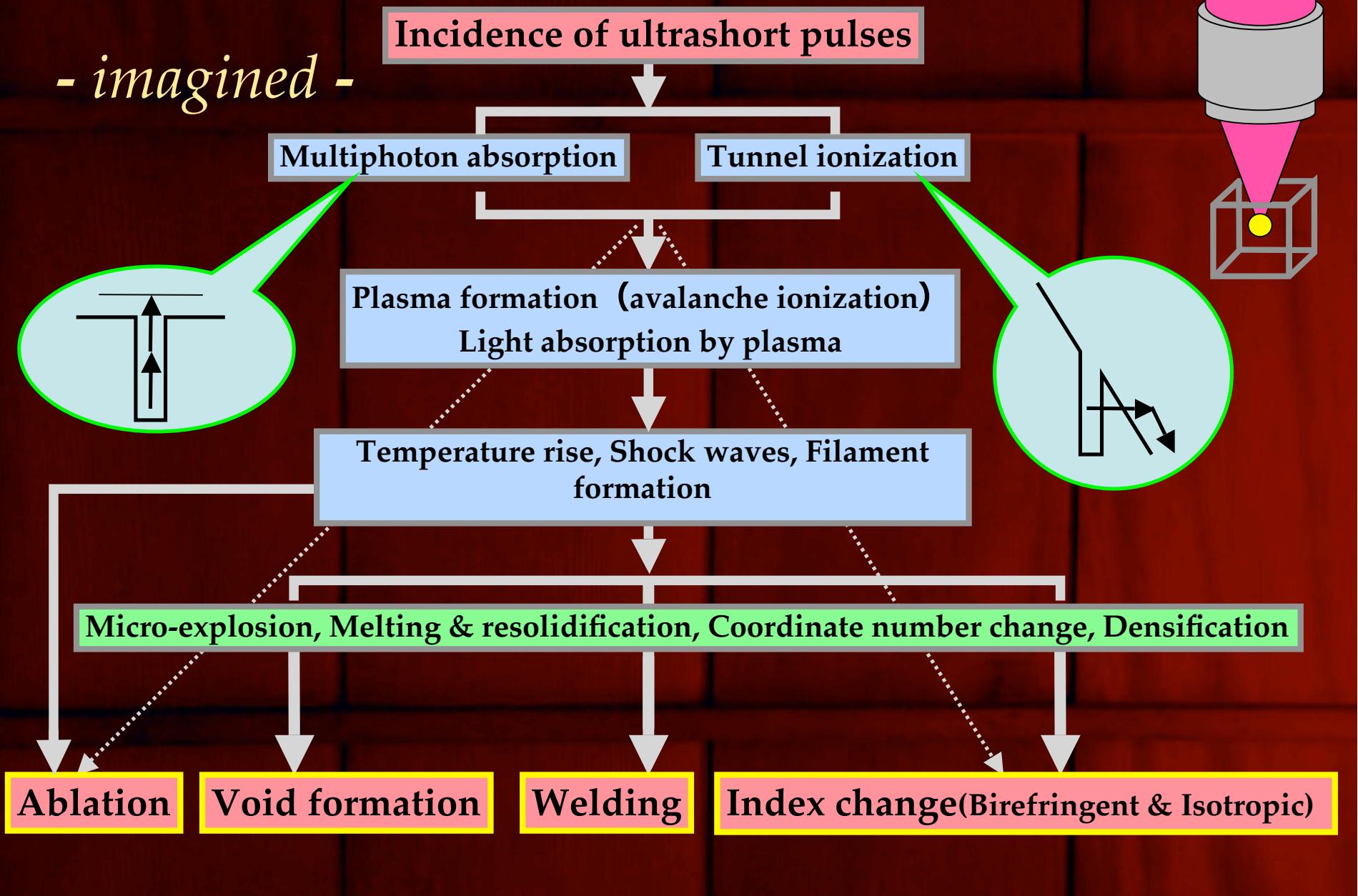
²National Institute of Advanced Industrial Science and Technology

Outline

- *Introduction to laser micro-processing*
- *Fabrication of optical devices with filaments*
- *Ultra-fast laser micro-welding of glass with filaments*
- *Ultra-fast laser micro-welding of heterogeneous materials*

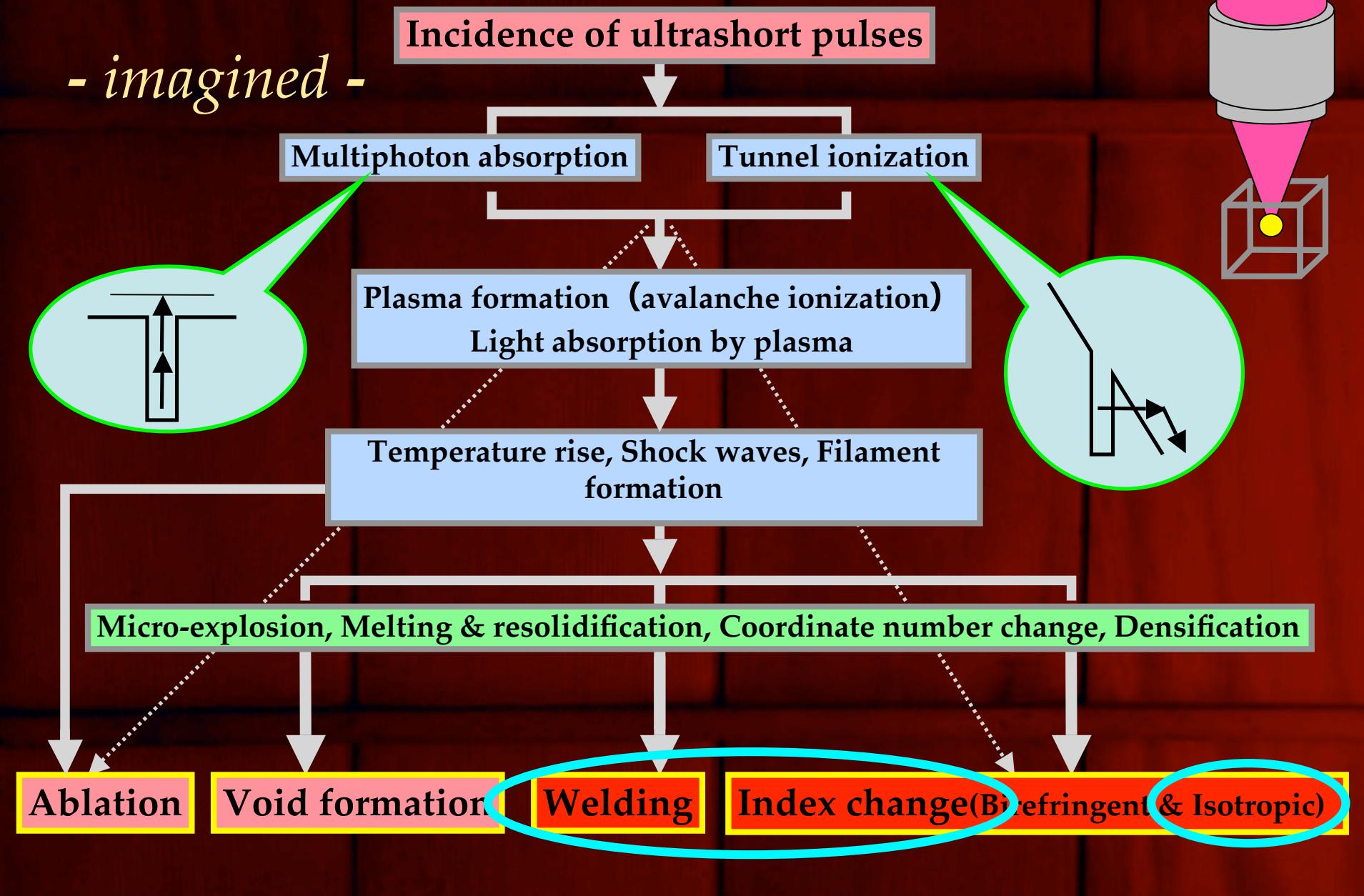
Process of structural changes

- imagined -



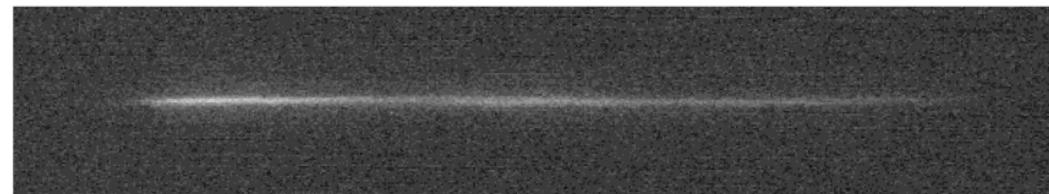
Process of structural changes

- imagined -



Filamentation

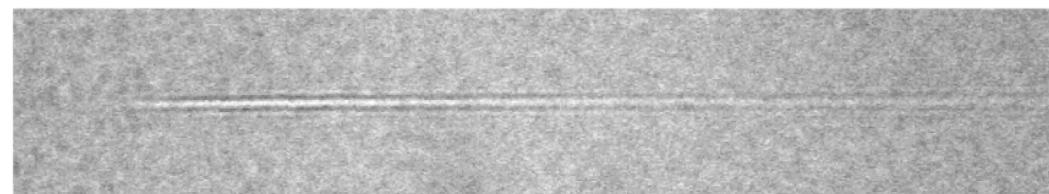
- balancing between self-focusing and defocusing by plasma -



(a)

Scattering or luminescence from filament

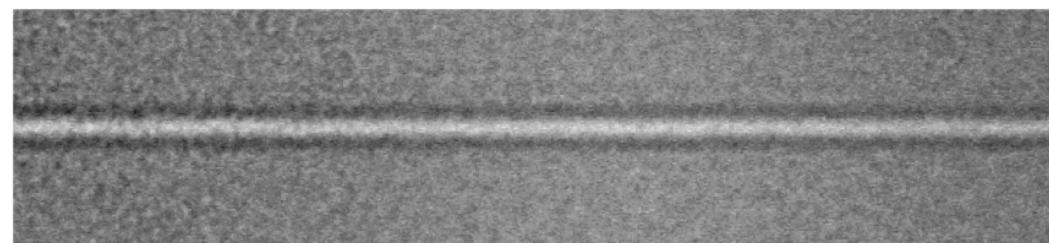
200 μm



(b)

Micrograph of the resultant index change

200 μm



(c)

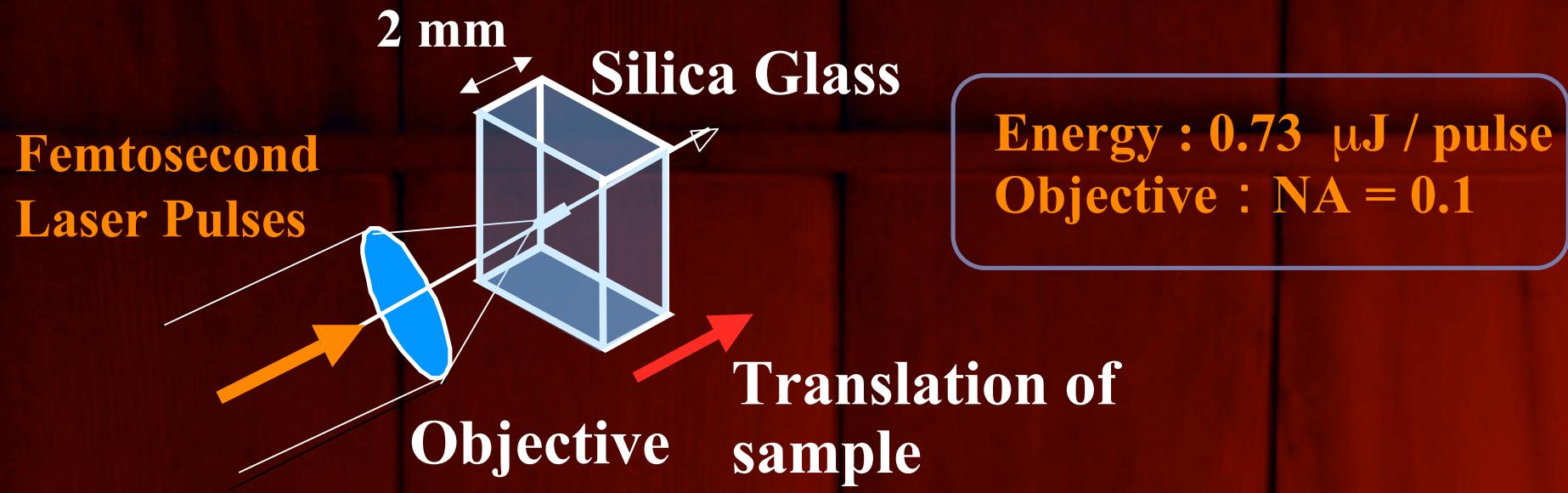
Magnified
micrograph

$\rightarrow z$

50 μm

*- Fabrication of optical devices
with filaments*

Fabrication of Waveguide



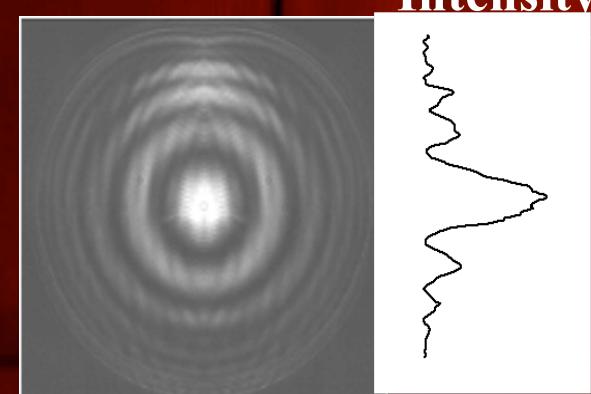
Energy : 0.73 μJ / pulse
Objective : NA = 0.1

Waveguide

Core diameter : 2 μm

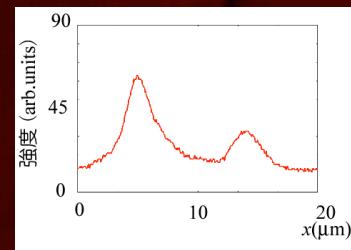
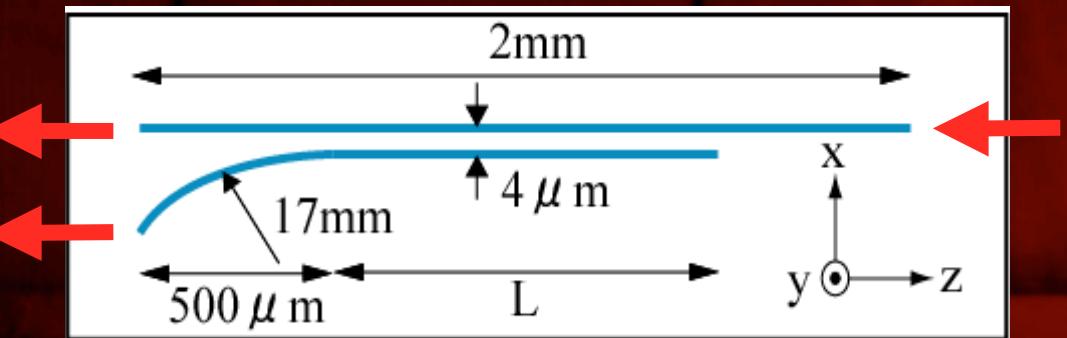
← Total length 2mm →

$\Delta n_z = 0.4 \times 10^{-2}$ $\Delta n_{x,y} = 0.6 \times 10^{-2}$

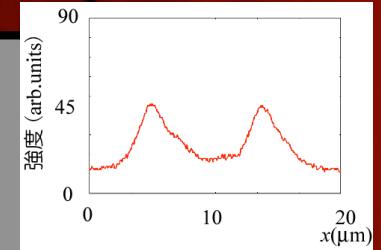


Far-field Pattern
(Wavelength: 633 nm)

2-D Directional Coupler



$L=0.5\text{mm}$

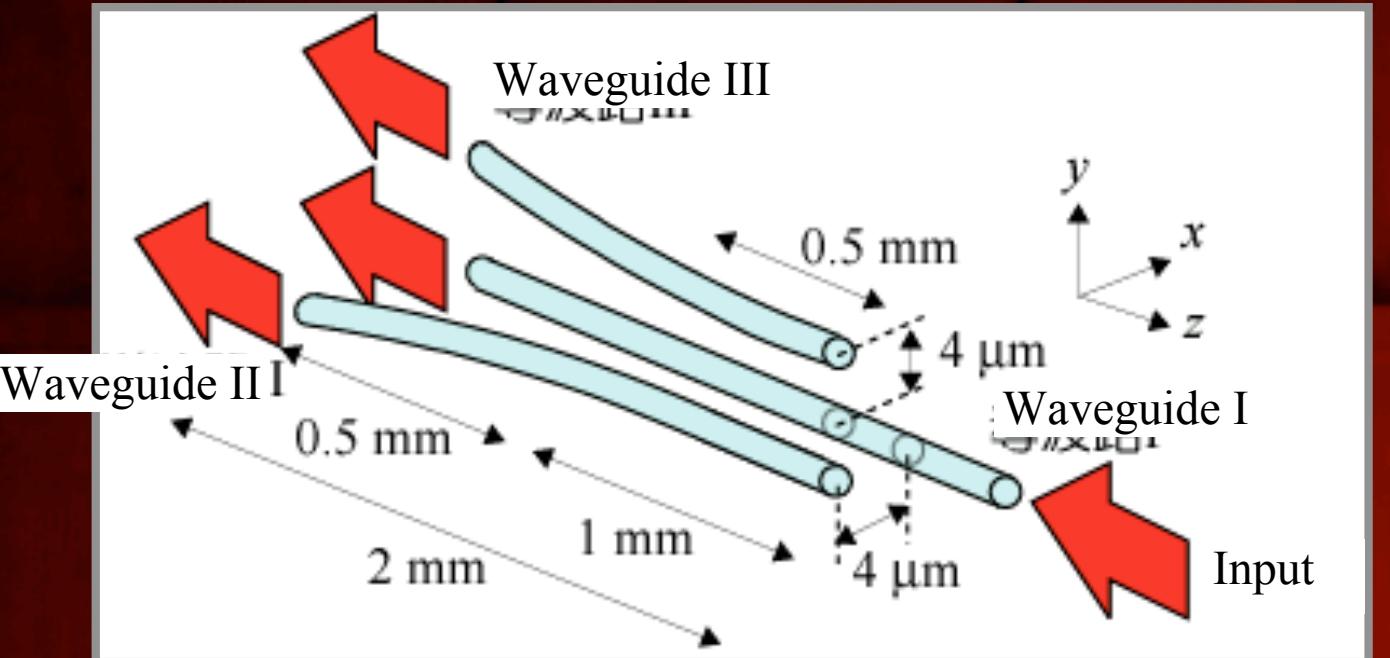


$L=1\text{mm}$

He-Ne laser
633 nm

Near field pattern at end face of glass block

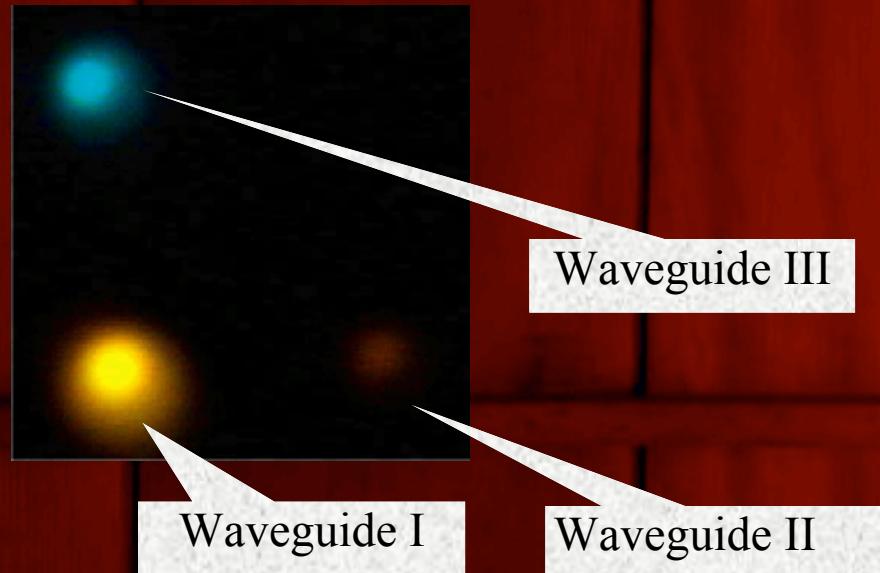
3-D Coupler



Input light : 632.8 nm

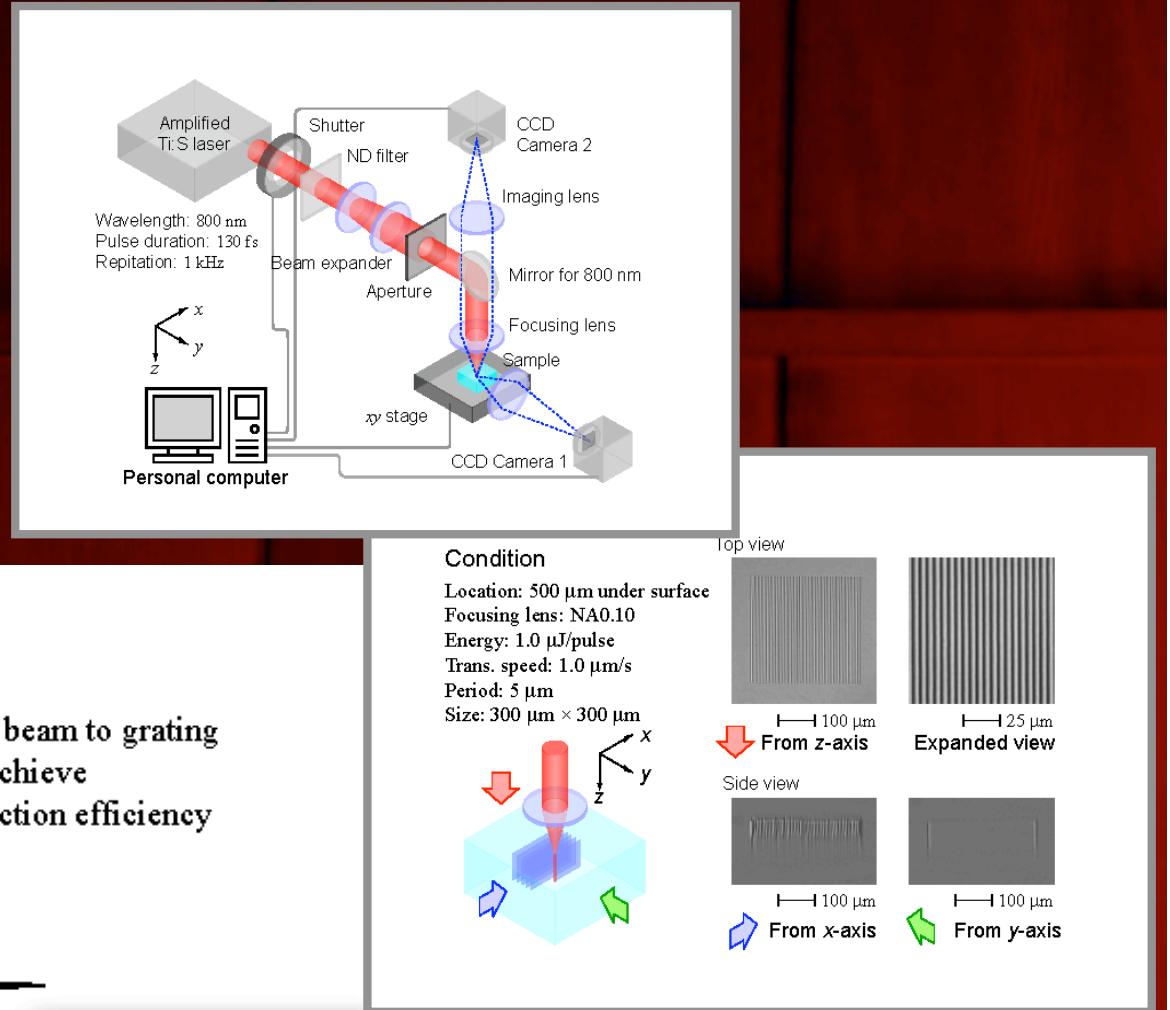
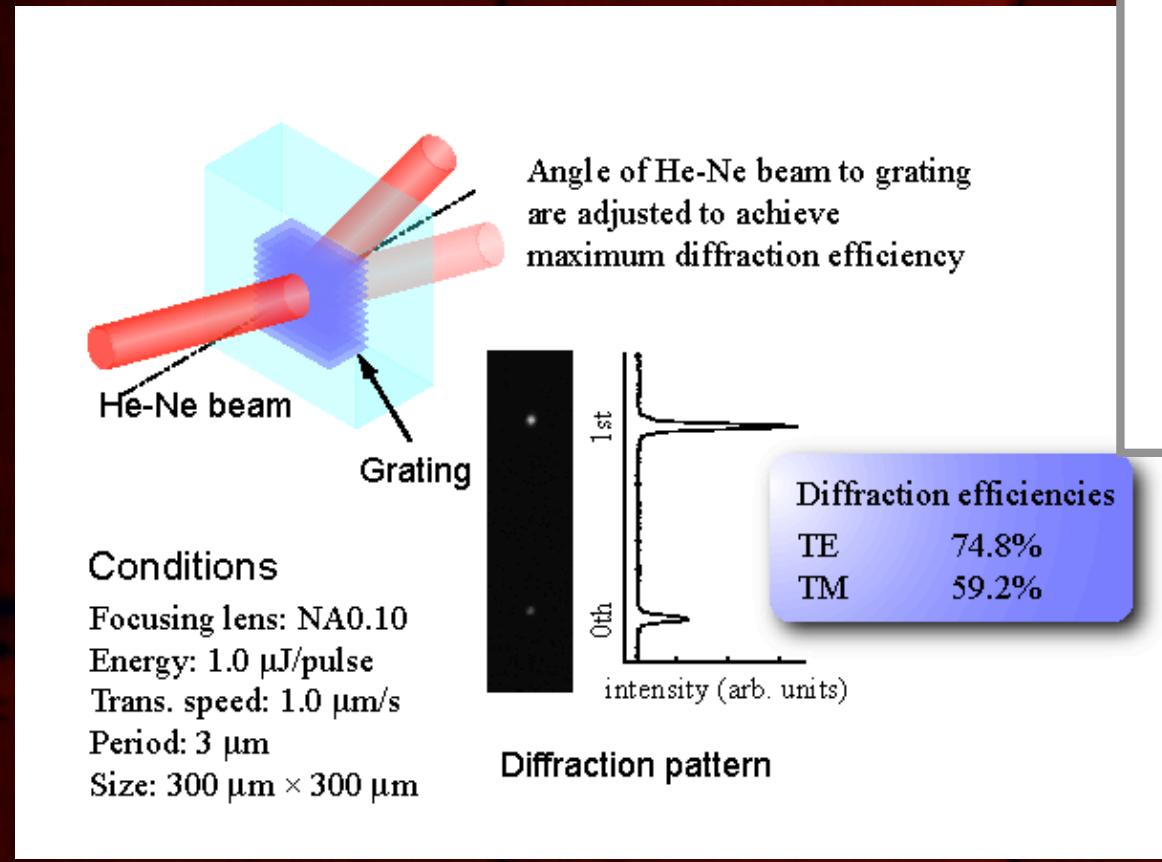


Input light : White light

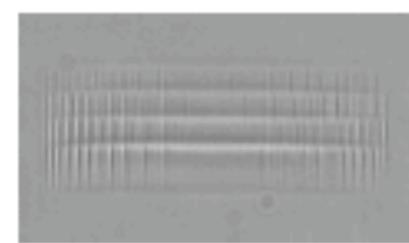
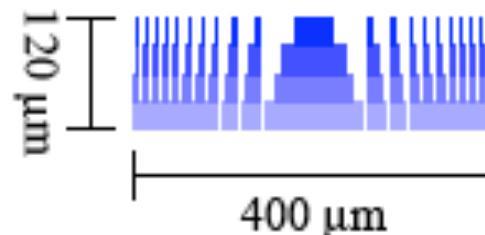
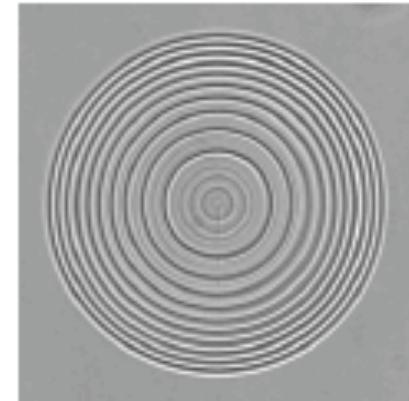
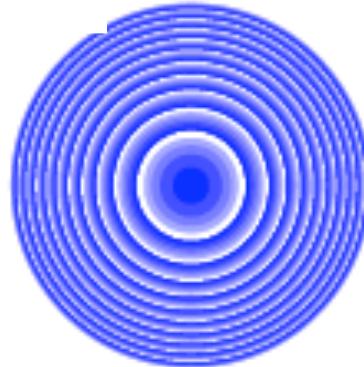
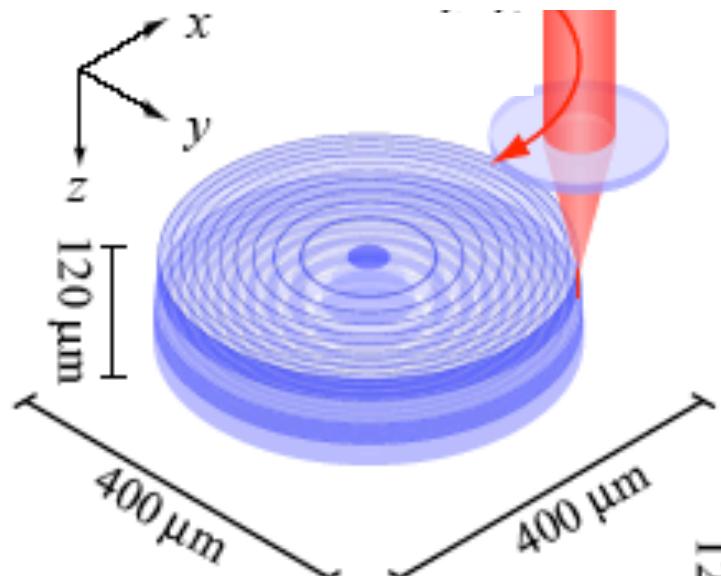


Fabrication of Bragg grating

K. Yamada et al, Jpn. J. Appl. Phys., Vol. 42, Part 1, No. 11, 6916(2003).



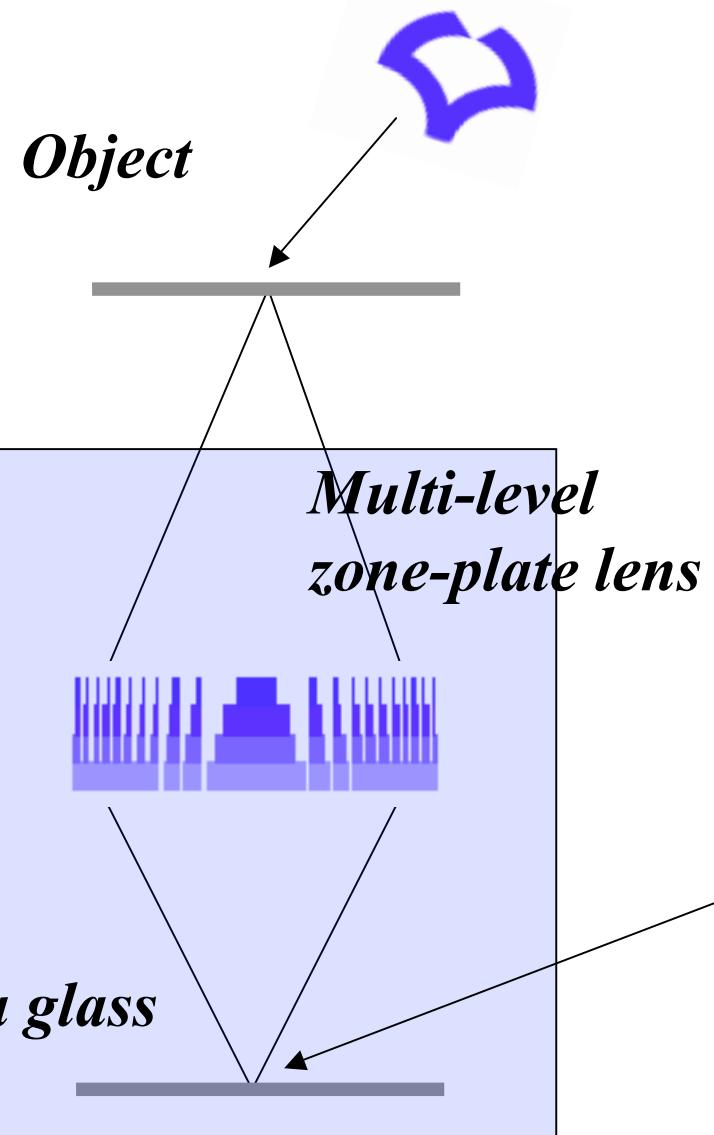
Multi-Level Phase Zone Plate Lens



Beam	NA 0.30
Energy	0.8 μJ/pulse
Wavelength	5 μm/s
Focal Length	632.8 nm
Thickness	3 mm
Layers	30 μm 4 layers



Diffraction. eff. 28.1 %
Focal Spot Size 7.3 μm

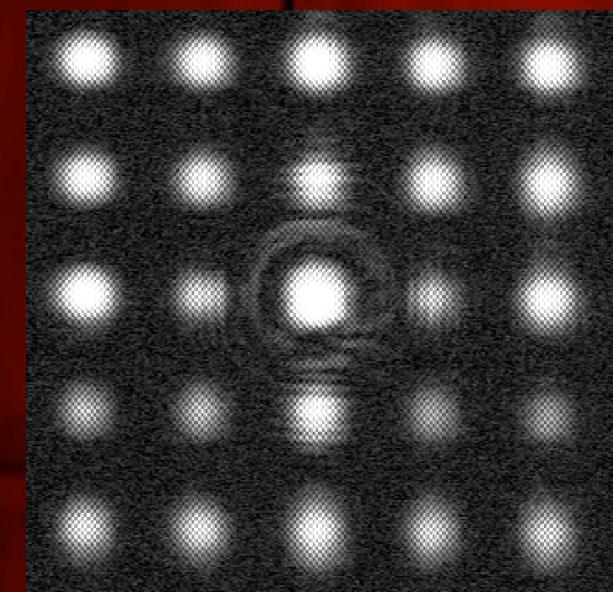
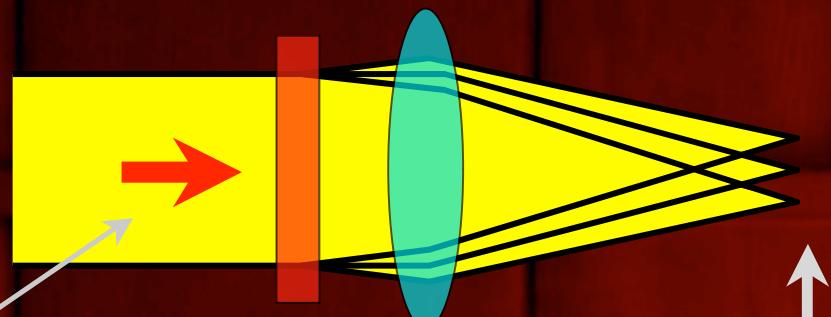
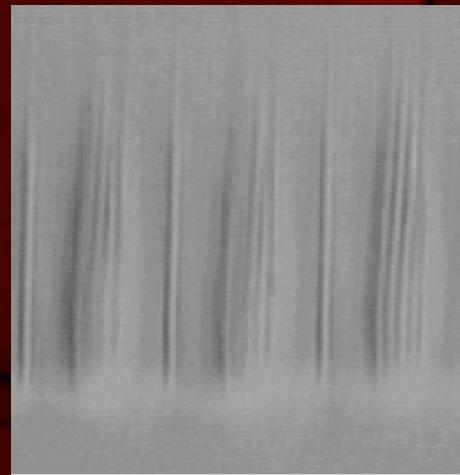
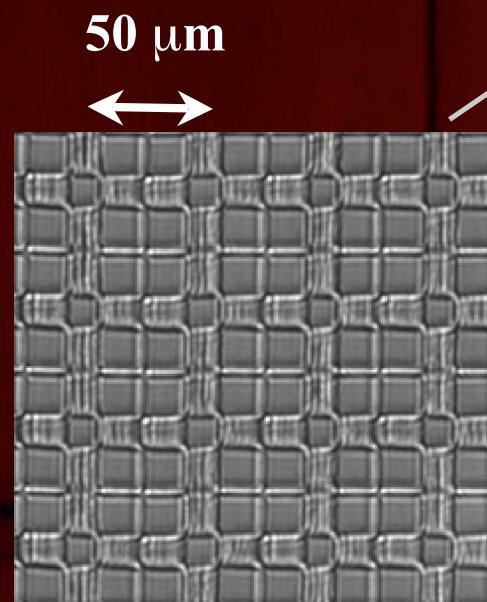


*Image formed
by zone-plate lens
in silica glass*



Fabrication of Dammann grating

Dammann grating

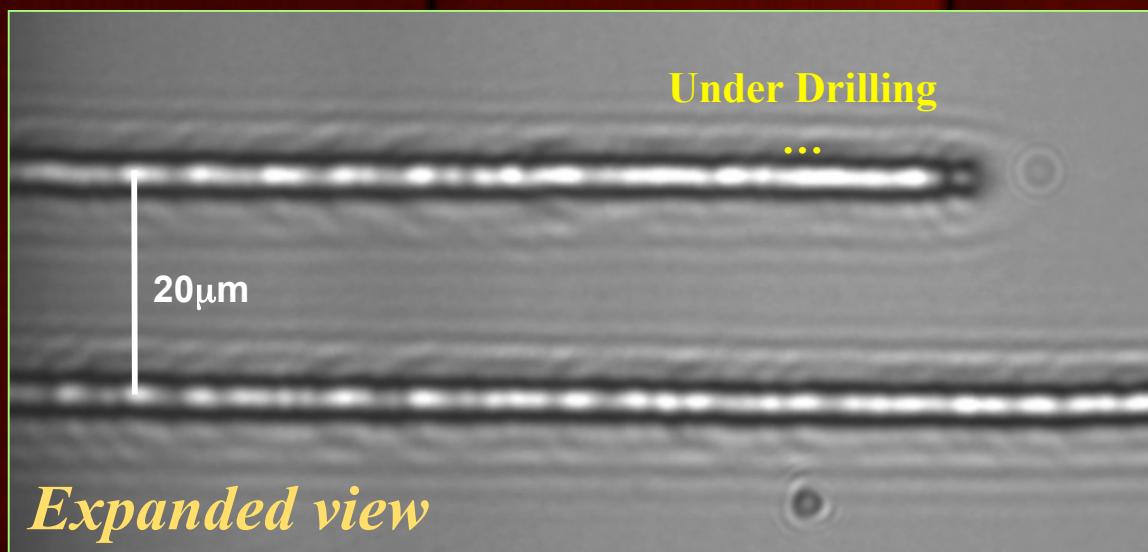
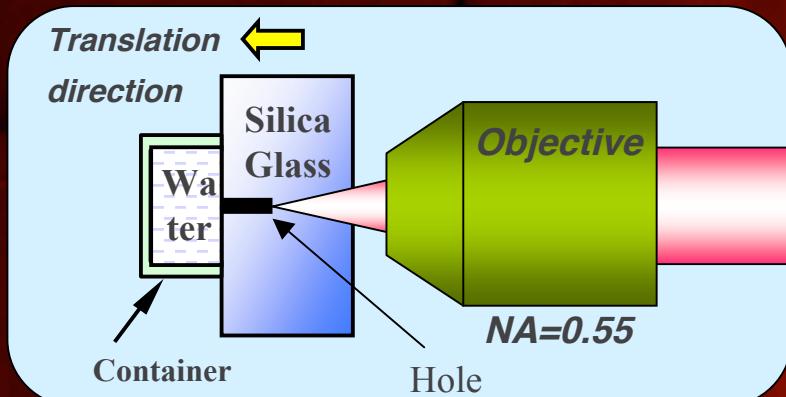


Drilling micro holes

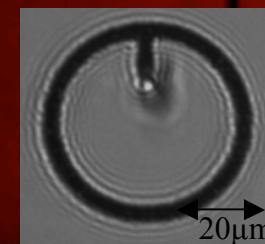
Incident Power : 1 mW (1 μ J/pulse)

Translation Step: 1 μ m

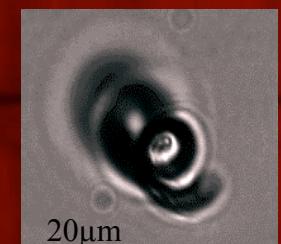
Exposure Time : 3 × s /point (48 pulses)



- Small diameter
- High aspect ratio (>50)
- Well-defined wall



*Circular &
Helical holes*



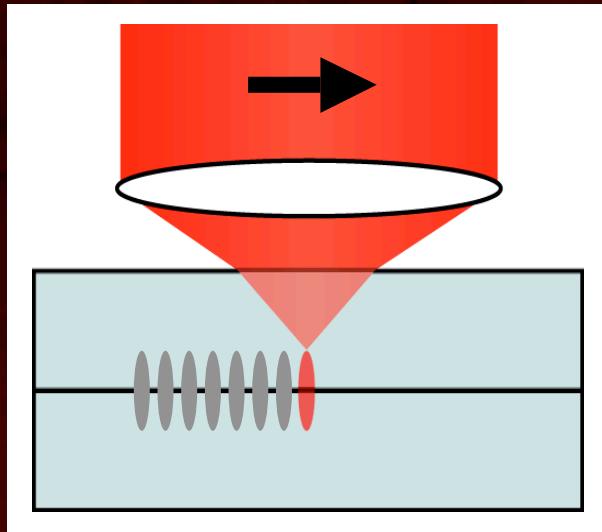
*- Ultra-fast laser micro-welding
of glass with filaments*

Takayuki Tamaki, Wataru Watanabe, Junji Nishii, and Kazuyoshi Itoh, *Jpn. J. Appl. Phys.*, Vol. 44, No. 22, L687-L689 (2005).

Takayuki Tamaki, Wataru Watanabe, and Kazuyoshi Itoh, *Optics Express*, Vol. 14, Issue 22, 10460-10468 (2006).

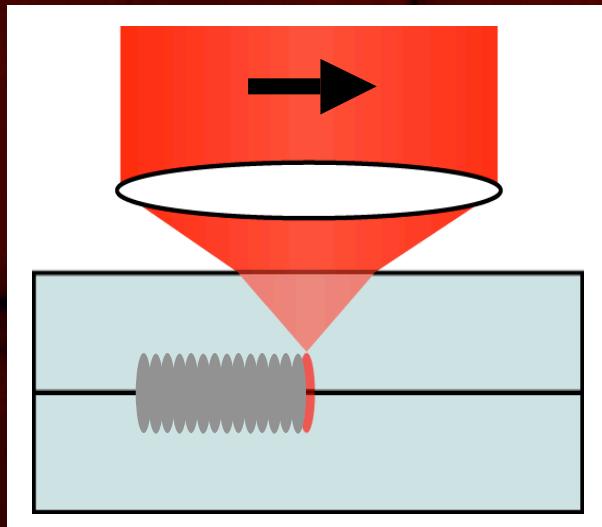
W. Watanabe, S. Onda, T. Tamaki, and K. Itoh, *Appl. Phys. B*, Vol. 87, pp. 85-89 (2007).

Scanning the filament



Low repetition source
Fast scanning

\sim *Gap*

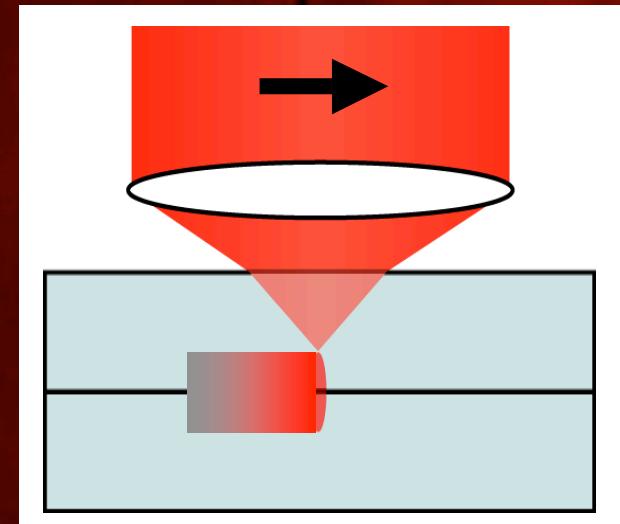


Low repetition
Slow scanning

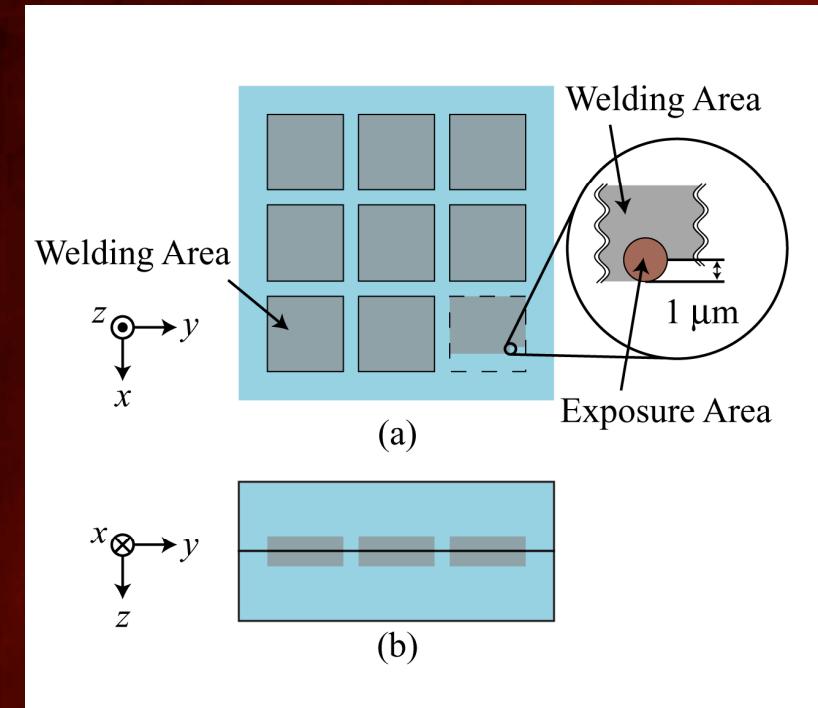
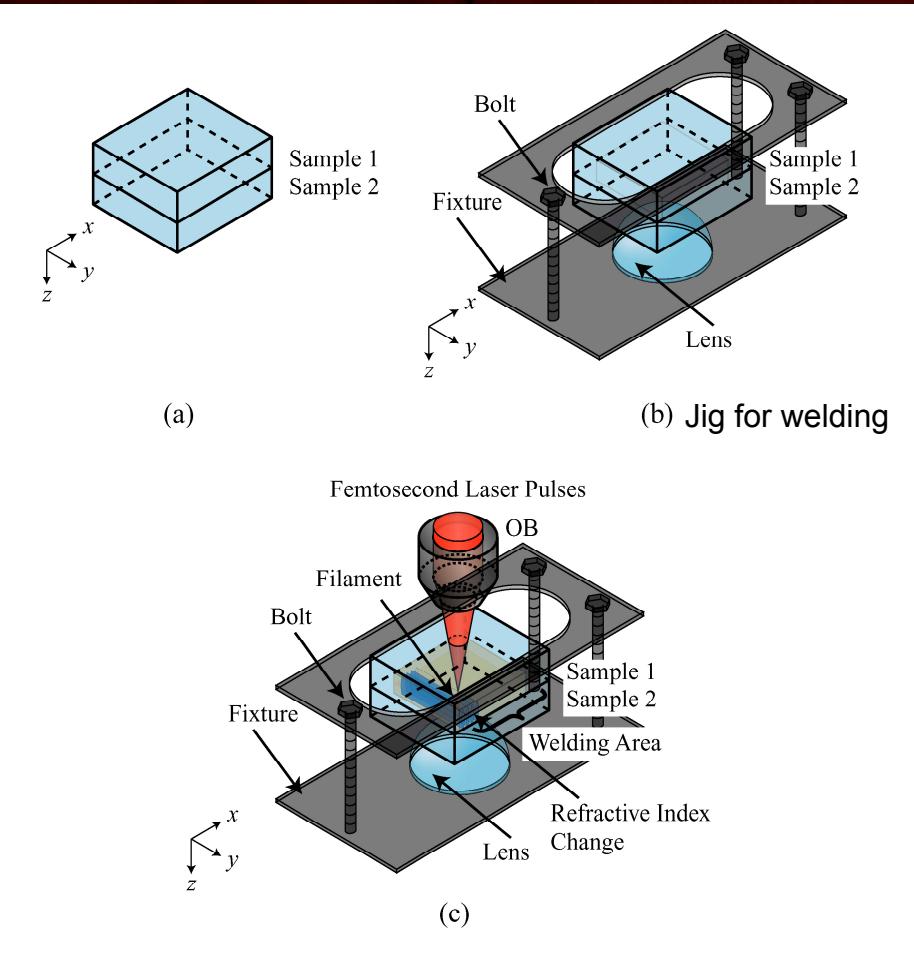
\sim *No gap*

High repetition source

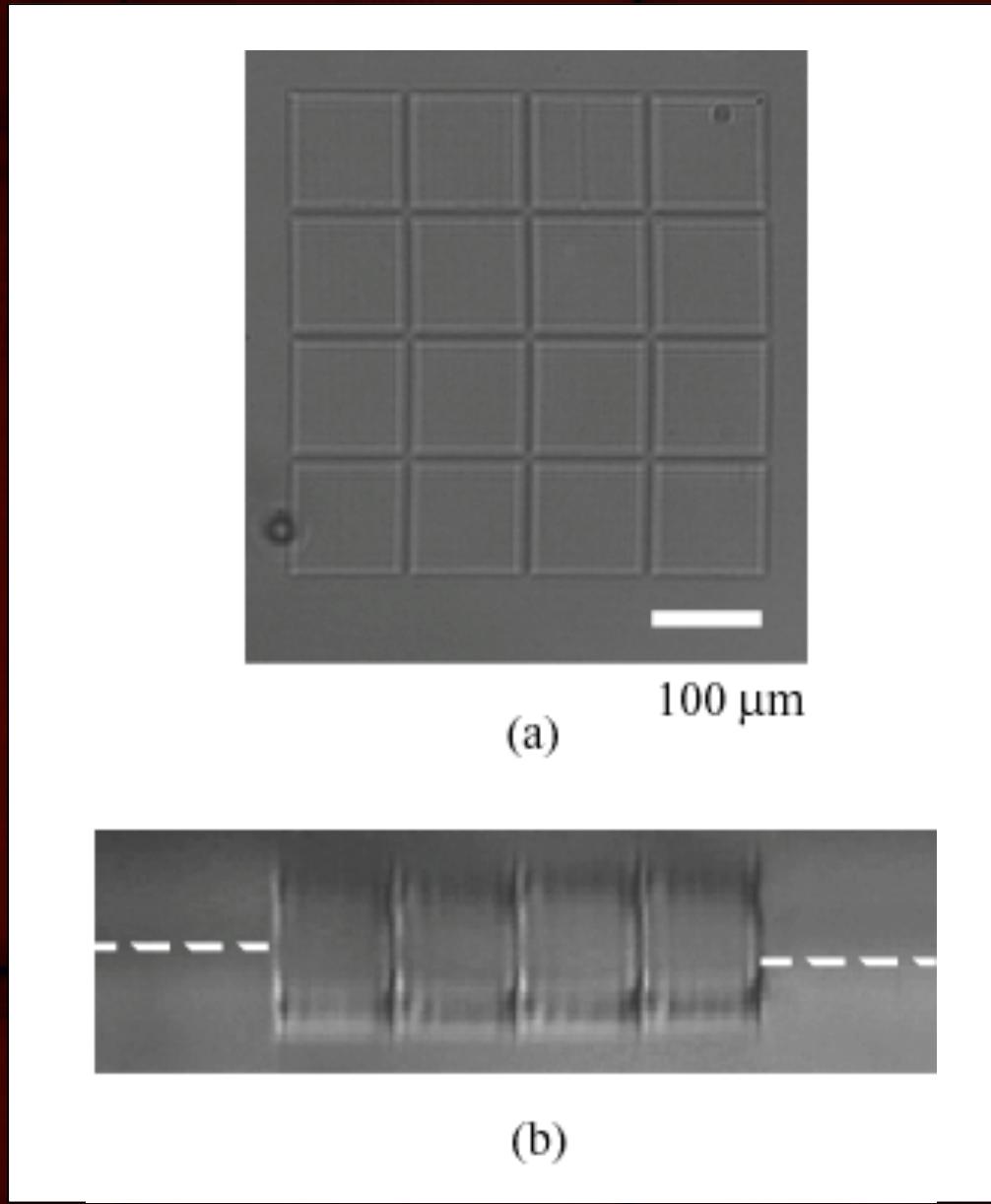
\sim *Accumulation of heat*



Welding flat samples



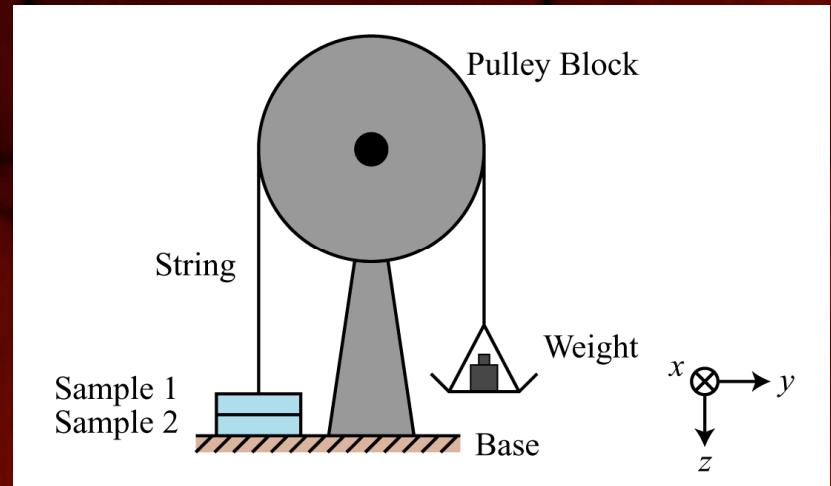
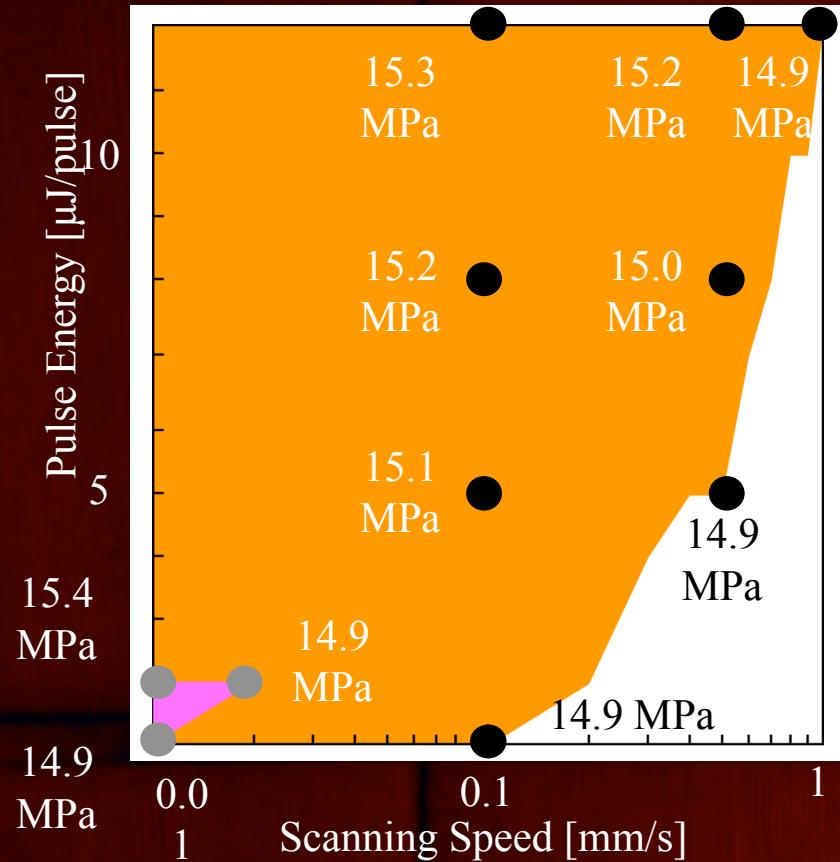
Micrographs



Top view

Side view

Joining strength (Same material)



Borosilicate glass

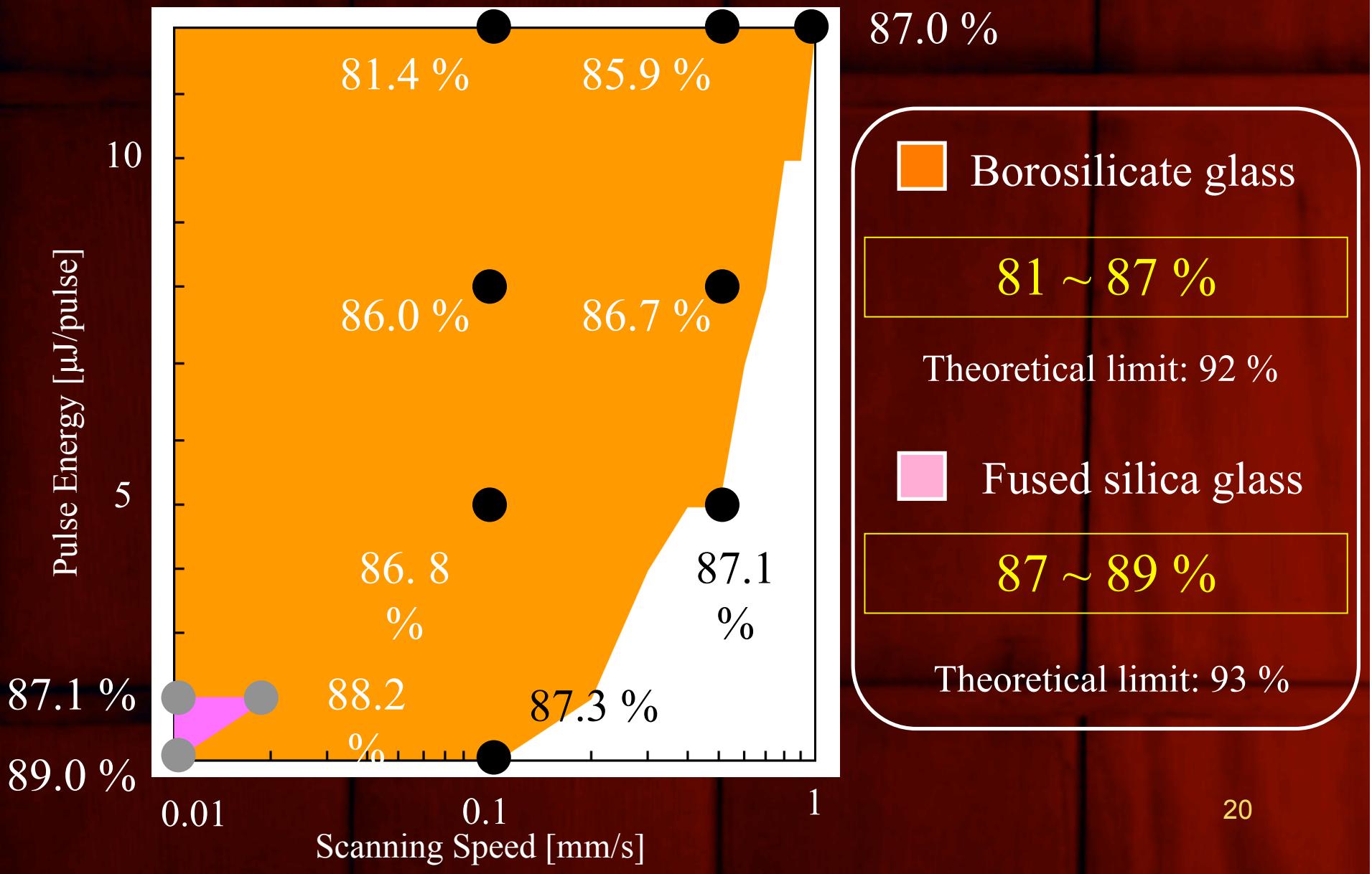
Fused silica glass

$15 \text{ MPa} \sim 150 \text{ kgf/cm}^2$

Usual adhesive $\sim 50 \text{ kgf/cm}^2$

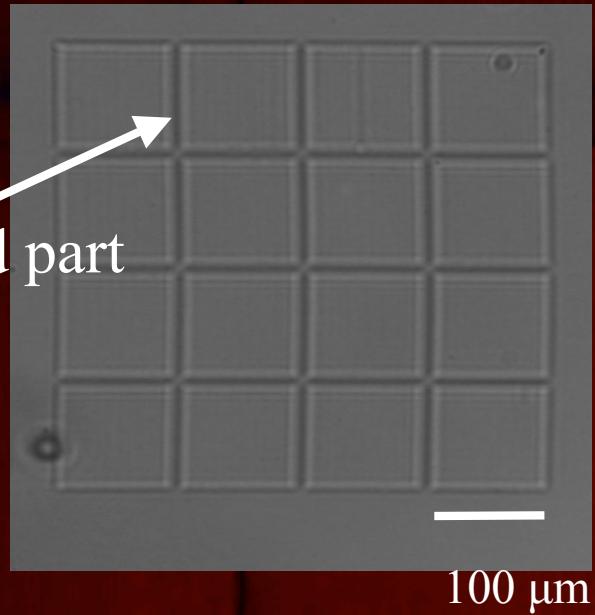
(kgf: kilogram force)

Optical transmittance



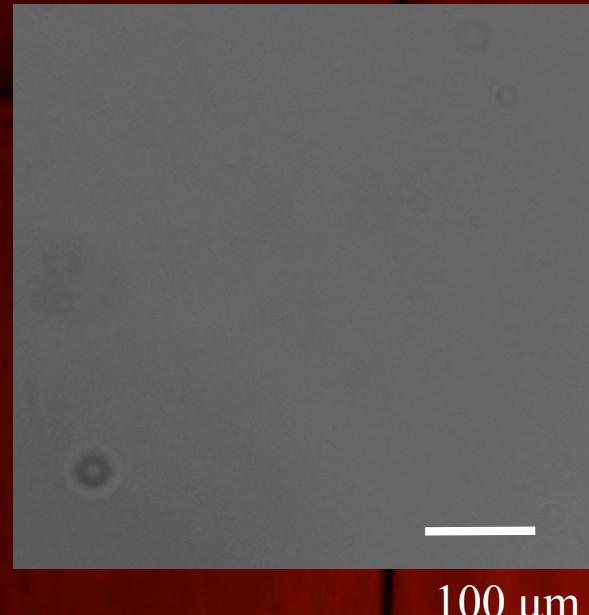
Effects of Annealing

Welded part



*Micrograph
before annealing*

100 μm



*Micrograph
after annealing*

100 μm

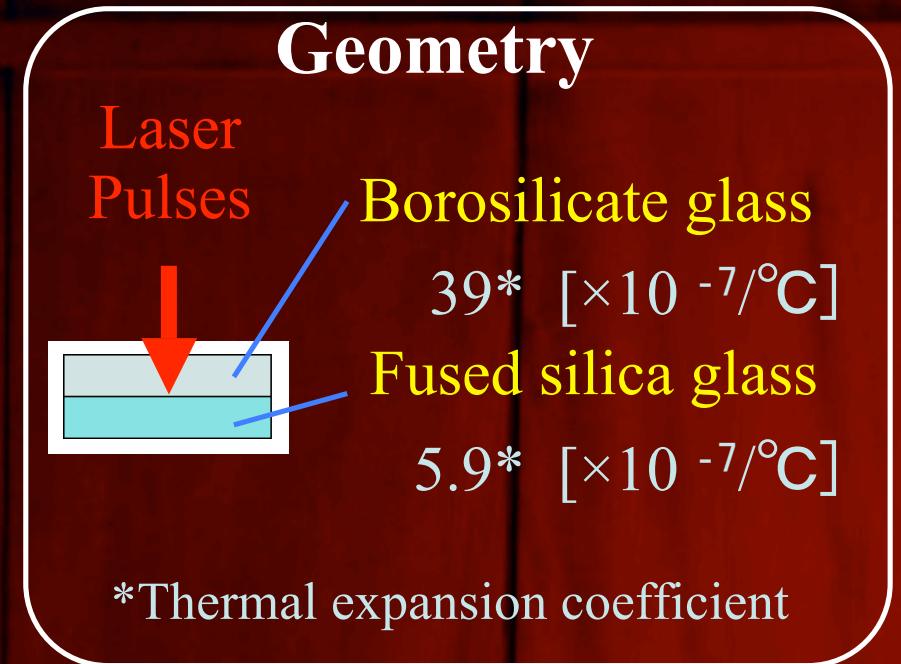
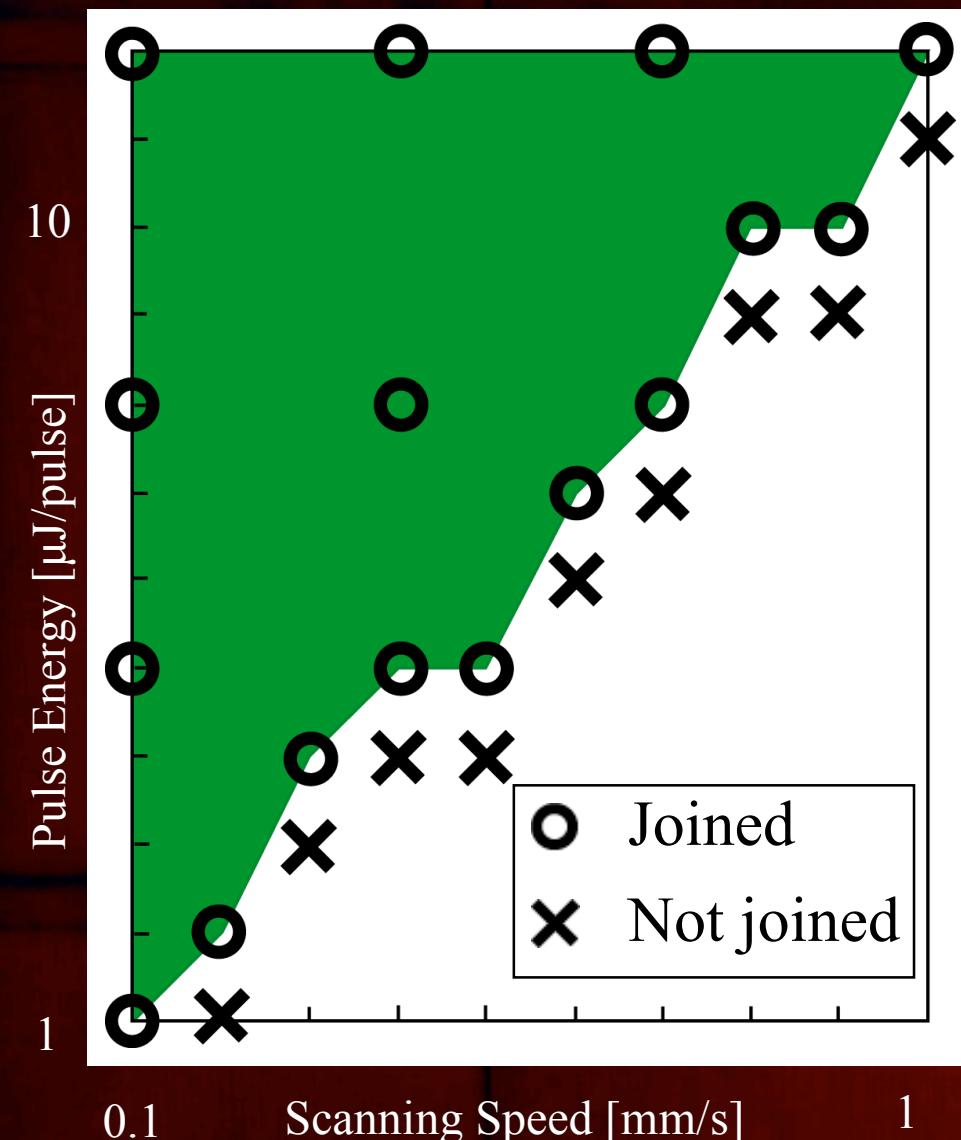
Annealing makes welded part invisible.
(Implication of disappearance of defects.)

Enhancement of joining strength & optical transmittance

<i>Joining strength</i>	Borosilicate glass	Fused silica glass
Before annealing	15 MPa	15 Mpa
After annealing	33 MPa	33 MPa
<i>Optical transmittance</i>		
Before annealing	88 %	87 %
After annealing	92 %	91 %:
	Theoretical limit: 93 %	Theoretical limit: 92 %

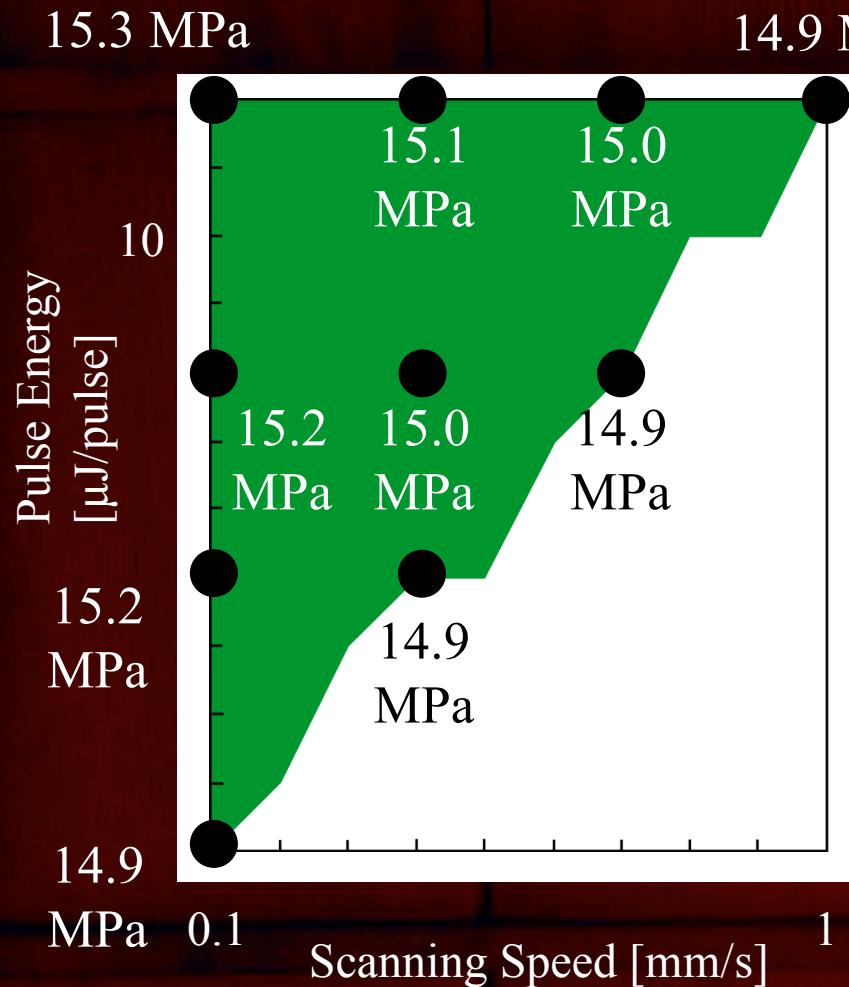
*- Ultra-fast laser micro-welding
of different glass*

Heterogeneous welding: dissimilar kinds of glass

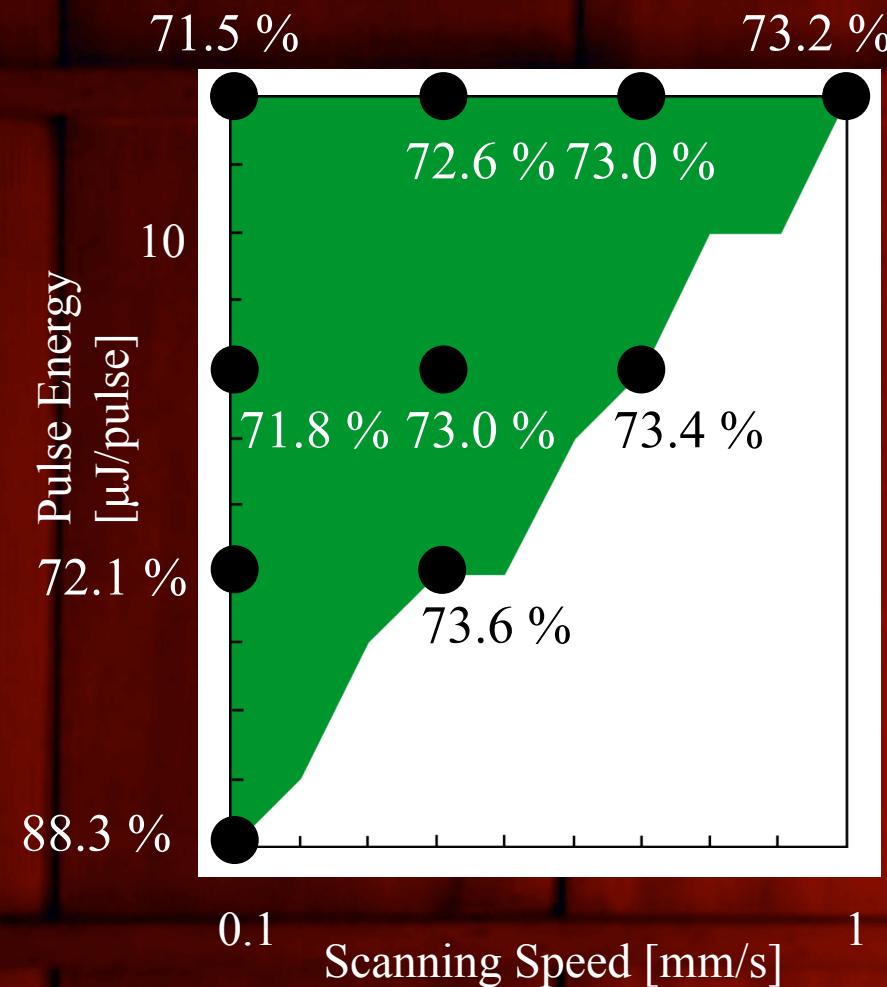


Wataru Watanabe, Satoshi Onda, Takayuki Tamaki,
Kazuyoshi Itoh, and Junji Nishii,
Appl. Phys. Lett., Vol. 89, No. 2, 021106 (2006).

Joining strength and transmittance



Joining strength

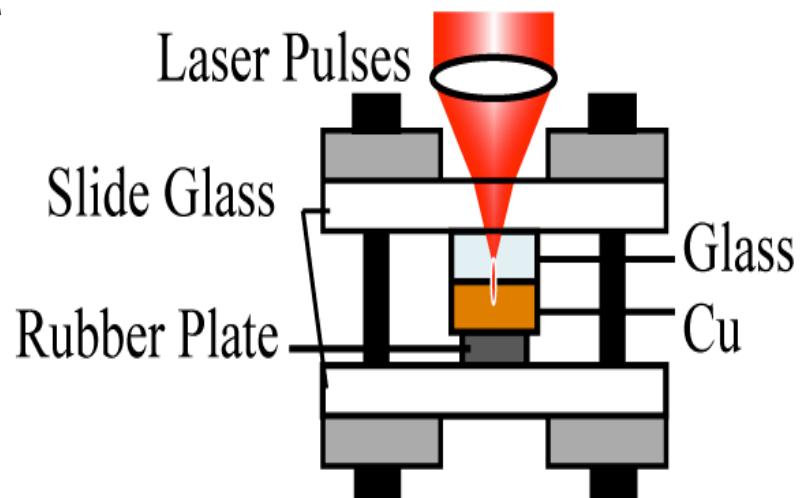


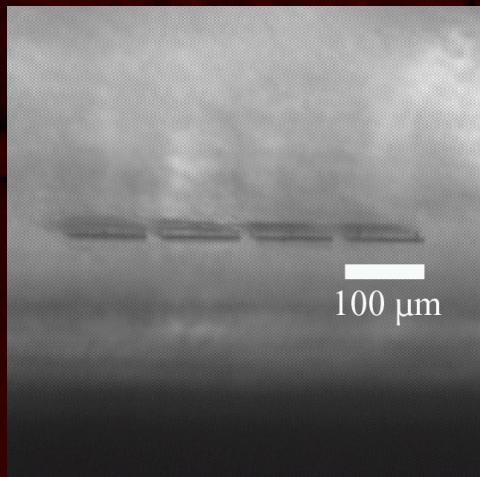
Optical transmittance 25

*- Ultra-fast laser micro-welding
of glass and metal*

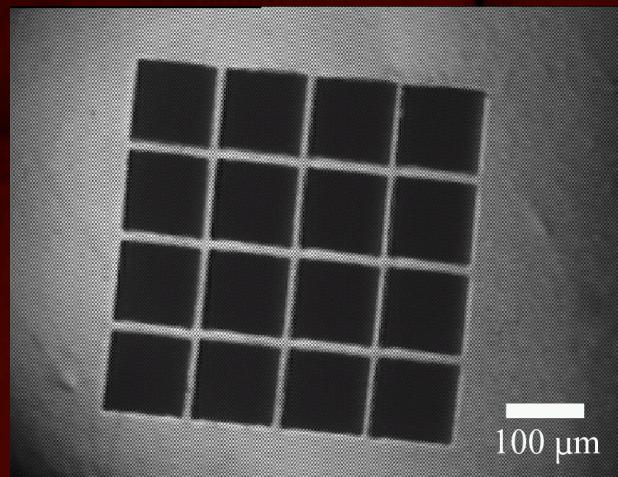
Ultra-fast Laser Micro-welding of Glass and Copper

**Realizing tight contact
between
glass and copper**

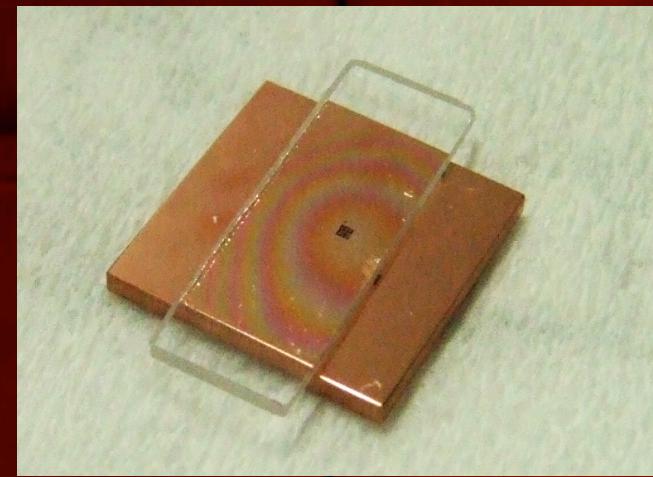




(a) Side view



(b) Top view



(c) Whole image

Optical microscope images

Laser source: Regenerative Ti:sapphire laser
(Spectra Physics, Spitfire)

Central wavelength: 800 nm

Pulse duration: 130 fs

Repetition rate: 1 kHz

Pulse energy: 4 μ J/pulse

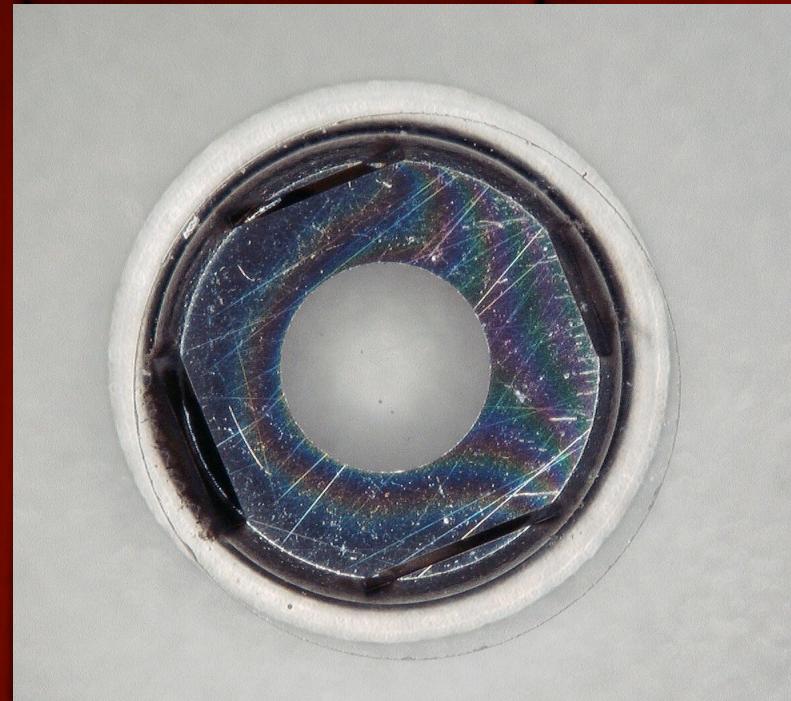
Scan speed: 1 mm/s

Joining strength:
23 MPa

Application of Ultra-fast Laser Micro-welding to Metal Package (Glass & Kovar)



(a) Birds-eye view



(b) Top view

Coworkers:

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Dr. Yasuyuki OZEKI and Mr. Tomoyuki INOUE

Osaka University

Mr. Satoshi ONDA

Yokogawa Electric Corporation

Mr. Seiji SOWA

Konica Minolta Opto, Inc.

